



**PATENT APPLICATION**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In Re Application Of	)	
	)	Group Art Unit: 2811
Hisato Oyamatsu	)	
	)	Examiner: T. Tran
Serial No.: 10/612,988	)	
	)	
Filed: July 7, 2003	)	
	)	
For: A SEMICONDUCTOR DEVICE	)	Atty. Dkt. No. 01701.00188
WITH AN IMPROVED GATE	)	
ELECTRODE PATTERN AND A METHOD	)	
OF MANUFACTURING THE SAME	)	

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**SUPPLEMENTAL PRELIMINARY AMENDMENT**

The Applicant requests that the following amendments be entered prior to an action on the merits.

**Amendments to the Claims** begins on page 2 of this paper.

**Remarks** begin on page 4 of this paper.